

Nitrogen-14 Nuclear Magnetic Resonance Studies of Trifluoramine Oxide, Nitrogen Trifluoride, and Related Compounds

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TRIFLUORAMINE OXIDE,¹⁻³ ONF₃, is an unusual amine oxide, with NF₃ a non-basic amine. The NO stretching frequency, 1690 cm.⁻¹, resembles the 1600 cm.⁻¹ found in CF₃NO⁺ rather than the 950—970 cm.⁻¹ in the amine oxides R₃N⁺-O⁻ (formed by the more basic amines). This double-bond character in ONF₃ is attributed¹ to delocalisation of lone-pair (in this case n_o) electrons into NF σ* orbitals, as in CF₄ and chlorofluoromethanes, enhanced by the high effective electronegativity of the nitrogen.

We have measured the ¹⁴N n.m.r. shifts of ONF₃, and of NF₃, NOF, NO₂F, CF₃NO, and CF₃NO₂, with wide-line (Varian 4300B) equipment, and nitromethane as external reference. Relative to saturated aqueous nitrite ion, the shifts (in brackets, line-widths at half-height) in p.p.m. are: ONF₃, +376 (208) at -120°; NF₃, +238 (225) at -130°; NOF, +128 (90) at -60° to -105°; NO₂F, +297 (52) at -65° to -155°. The spin-spin structure is not resolved. The shift for CF₃NO is -193 (140) at -90° to -130°, and for CF₃NO₂ (preliminary value) +225 (35) at -60°. The ¹⁹F resonance for NO₂F is -221 p.p.m. from CFCI₃ at -60°.

The Figure compares the ¹⁴N shift, on removal of the oxygen from nitrogen in ONF₃ to leave :NF₃, with corresponding shifts for related compounds. The alkylamines,⁵ ammonia,⁵ and ammonium ions,⁵ with trimethylamine oxide^{5,6} and hydroxylammonium ions,⁵ clearly form a class of their own. All the other compounds have nitrogen resonances at lower field, and show systematic downfield shifts on removal of the oxygen atom, to leave NF₃, or a

nitrosyl or nitroso-compound (aromatic† or aliphatic C·N̄:O, R₂NNO⁷); nitrite ion or RONO†; N₂O₃,⁷ an azine,⁵ or a furazan,⁶ or even nitrogen⁸ (liquid, compared with N₂O⁸).

Theory⁹ shows that the de-shielding mainly depends on the magnetic excitation of electronic states, involving rotation of charge, e.g. n → π* or σ*, σ or σ* ↔ π or π*, and is inversely proportional, roughly, to the energy ΔE of the most accessible of these, often n → π*, or n → σ* if there is no π* orbital. This ΔE varies from ca. 10 ev for saturated molecules, resonating at high field, to ca. 2 ev for the blue C-nitroso-compounds, at very low field.

The methylamines and ammonia have ¹⁴N resonances within a small range, 10—15 p.p.m., at high field. The shift on protonation is very small and downfield, showing that the n_N electrons are not active in paramagnetic de-shielding. Addition of oxygen at the nitrogen lone pair moves the resonance downfield by nearly 100 p.p.m., due to the inductive effect on the diamagnetic shielding, to σ → σ* transitions between CN and NO bonds, and to n_o → π* states. In all other cases, the removal of oxygen from nitrogen to leave a lone pair, like the de-protonation of azines,^{5,10} allows de-shielding by n_N → π* or σ* excitation (cf. pyridine, the N-oxide, and N-hydroxonium ion⁹).

The XNO₂ compounds, with no n_N electrons, have rather similar shifts (Figure), showing a similar effect at nitrogen of the σ → π* transitions. In contrast the X·N̄:O line

† Measured by L.-O. Andersson, Varian Research Laboratory, Zürich.

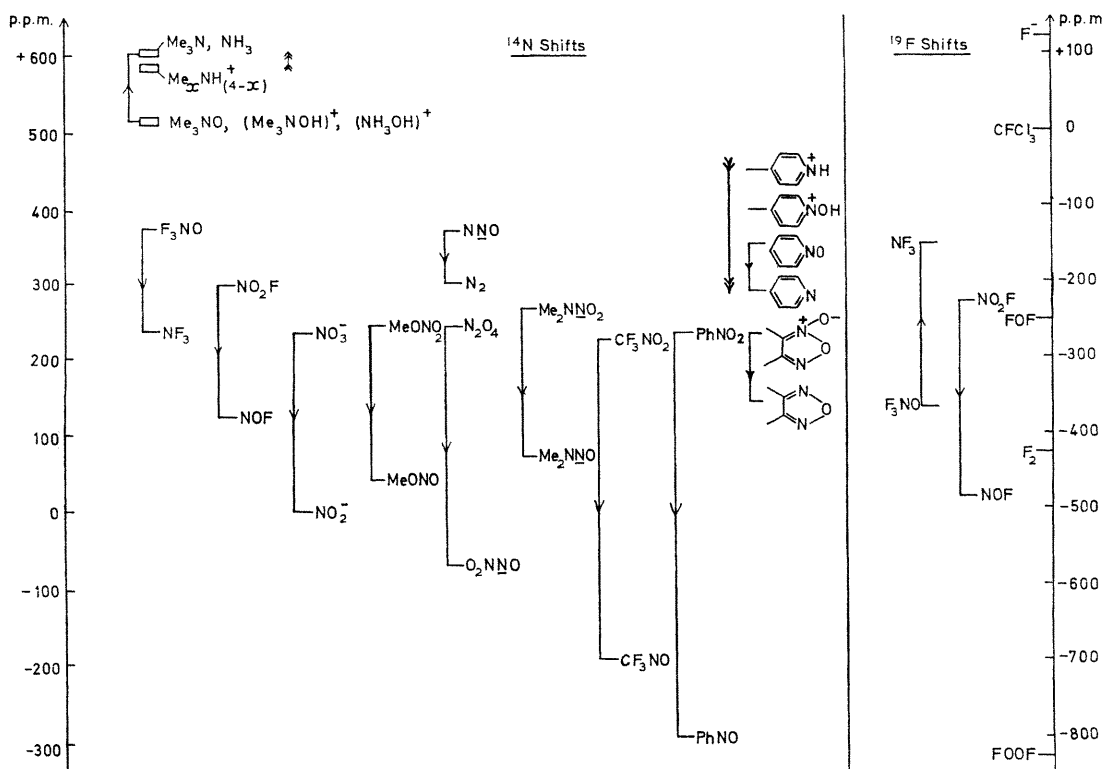


FIGURE. S shifts on removal of O from N: (\longrightarrow) and on deprotonation: ($\gg\longrightarrow$).

moves upfield as the $n_{\text{N}} \rightarrow \pi^*$ band shifts to higher frequency with increasing inductive stabilisation of the lone pair, in the order $\text{C:NO} < \text{O}_2\text{NNO} < \text{NO}_2^- < \text{NOF} < \text{NF}_3$; and in RONO , R_2NNO , and NOF , also with raising of the π^* orbital by inflow of n_{X} electrons.

In NF_3 , $n \rightarrow \sigma^*$ excitation can explain the de-shielding relative to NH_3 and the amines (although the u.v. spectrum of NF_3 is rather featureless)¹¹. The $\text{NF} \sigma^*$ orbitals must be quite low in energy as the bond is rather weak; $D(\text{F-NF}_2)$ is 57 kcal.mole.⁻¹, the radical NF_2 being rather stable.

The upfield shift of ONF_3 relative to the XNO_2 compounds probably reflects a smaller $\sigma \rightarrow \pi^*$ separation in XNO_2 as compared with the $\sigma_{\text{NO}} \rightarrow \sigma_{\text{NF}}^*$ separation in ONF_3 ; the latter is increased if n_{O} electrons move into σ^* orbitals. But the N-F bond in ONF_3 is weaker than in NF_3 ,³ and breaks before the N-O bond, in the mass spectrometer and in chemical reactions.¹ The pattern of the shifts

illustrates the difference between the N-O bond in ONF_3 and a true double bond, as in the C:N:O compounds.

In ^{19}F resonance, transitions of n_{F} (π -type) electrons are now the most important.⁹ NOF is downfield from NO_2F , but NF_3 is upfield from ONF_3 . The downfield shifts correlate, at lower fields, with the weakness of the bond to fluorine, *i.e.* with a lowering of the σ^* orbitals, and perhaps with de-stabilisation of the n_{F} electrons. $\text{FO}\cdot\text{OF}$ has a very long O-F bond¹² and a very low-field ^{19}F line,¹³ and is coloured (also at -196°).¹⁴

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¹ W. B. Fox, J. S. MacKenzie, N. Vanderkooi, B. Sukornick, C. A. Wamser, J. R. Holmes, R. E. Eibeck, and B. B. Stewart, *J. Amer. Chem. Soc.*, 1966, **88**, 2604; W. B. Fox, J. S. MacKenzie, E. R. MacCarthy, J. R. Holmes, R. F. Stahl, and R. Juurik, *Inorg. Chem.*, 1968, **7**, 2064.

² N. Bartlett, J. Passmore, and E. J. Wells, *Chem. Comm.*, 1966, 213.

³ E. E. Curtis, D. Pilipovich, and W. H. Moberly, *J. Chem. Phys.*, 1967, **46**, 2904.

⁴ J. Mason and J. Dunderdale, *J. Chem. Soc.*, 1956, 754.

⁵ D. H.-Evans and R. E. Richards, *Mol. Phys.*, 1964, **8**, 19.

⁶ G. Englert, *Z. Elektrochem.*, 1961, **65**, 854.

⁷ L.-O. Andersson and Joan Mason, *Chem. Comm.*, 1968, 99.

⁸ J. E. Kent and E. L. Wagner, *J. Chem. Phys.*, 1966, **44**, 3530.

⁹ A. Saika and C. P. Slichter, *J. Chem. Phys.*, 1954, **22**, 26; J. A. Pople, *Mol. Phys.*, 1963, **7**, 301, and refs. therein.

¹⁰ V. M. S. Gil and J. N. Murrell, *Trans. Faraday Soc.*, 1964, **60**, 248.

¹¹ S. R. la Paglia and A. B. F. Duncan, *J. Chem. Phys.*, 1961, **34**, 1003.

¹² R. H. Jackson, *J.*, 1962, 4585.

¹³ N. J. Lawrence, J. S. Ogden, and J. J. Turner, *Chem. Comm.*, 1966, 102.

¹⁴ A. D. Kirshenbaum and A. G. Streng, *J. Chem. Phys.*, 1961, **35**, 1440.